

DL3 高磁通耐热冲击材料
HIGH FLUX & THERMAL SHOCK RESISTANT FERRITE

DL3 为镍锌铁氧体材料，初始磁导率 (μ) 约 350，饱和磁通密度 (B_s) 约 350 mT (25 °C) / 280 mT (100 °C)，居里温度高于 200 °C。中等磁导率搭配约 $10^7 \Omega\cdot\text{m}$ 的高电阻率，使其在低磁通条件下维持极低的相对损耗因子 (15×10^{-6} @0.1 MHz / 30×10^{-6} @2.0 MHz)，信号失真与插入损耗小；优异的耐热冲击性能可承受回流焊的急剧温变，特别适合 SMD 型元件。典型应用为宽频与平衡-不平衡 (Balun) 变压器、共模与差模 EMI 抑制、射频调谐元件、中高频小功率电感与 RF choke，亦用于汽车 ABS 传感器等精密磁传感磁芯。在 DL 系列中，DL3 为基准通用型：需要更高灵敏度时选 DL4 (μ 约 600)；需要更高饱和磁通与耐温时选 DL5 / DL6；DL5H 则兼顾较高磁导率与较高 B_s 。

DL3 is a NiZn ferrite with an initial permeability (μ) of approx. 350, a saturation flux density (B_s) of approx. 350 mT at 25 °C (280 mT at 100 °C) and a Curie temperature above 200 °C. Its medium permeability combined with a high resistivity of about $10^7 \Omega\cdot\text{m}$ keeps the relative loss factor very low under low flux (15×10^{-6} at 0.1 MHz / 30×10^{-6} at 2.0 MHz), minimising signal distortion and insertion loss, while its excellent thermal-shock resistance withstands the rapid temperature swings of reflow soldering — well suited to SMD parts. Typical uses are wideband and balun transformers, common- and differential-mode EMI suppression, RF tuning elements, mid/high-frequency low-power inductors and RF chokes, as well as precision sensing cores such as automotive ABS sensors. Within the DL family, DL3 is the general-purpose baseline: choose DL4 (μ approx. 600) for higher sensitivity, DL5/DL6 for higher flux density and temperature capability, or DL5H to balance both.

- Wideband / Balun Transformer
- EMI Suppression
- RF Tuning
- Power Inductor / RF Choke
- Automotive Sensor

电磁特性 MAGNETIC CHARACTERISTICS

特性 Characteristic	条件 Condition	值 Value	单位 Unit
初始磁导率 μ Initial Permeability	100 kHz & <0.2 mT	350±25%	
饱和磁通密度 B_s Saturation Flux Density	3000 A/m · 25 °C 100 Hz	350	mT
饱和磁通密度 B_s Saturation Flux Density	3000 A/m · 100 °C 100 Hz	280	mT
残留磁通密度 B_r Remanence	3000 A/m · 25 °C 100 Hz	205	mT
残留磁通密度 B_r Remanence	3000 A/m · 100 °C 100 Hz	125	mT
矫顽力 H_c Coercivity	3000 A/m · 25 °C 100 Hz	45	A/m
矫顽力 H_c Coercivity	3000 A/m · 100 °C 100 Hz	40	A/m
$\alpha\mu$ (温度系数) Temperature coefficient of permeability	20 ~ 60 °C	25	$\times 10^{-6}/\text{K}$
相对损耗因子 $\tan\delta/\mu$ Relative Loss Factor	0.1 MHz & <0.2 mT	15	$\times 10^{-6}$
相对损耗因子 $\tan\delta/\mu$ Relative Loss Factor	2.0 MHz & <0.2 mT	30	$\times 10^{-6}$
居里温度 T_c Curie Temp.	100 kHz & <0.2 mT	>200	°C
密度 D Density	阿基米德法 Archimedes method	5.0	g/cm^3
电阻率 ρ Volume Resistivity	直流电流 DC Current	10^7	$\Omega\cdot\text{m}$
功率损耗 P_{cv} Power Loss	100 kHz/100 mT 500 kHz/30 mT 1 MHz/30 mT · 25 °C	925 422 1160	kW/m^3

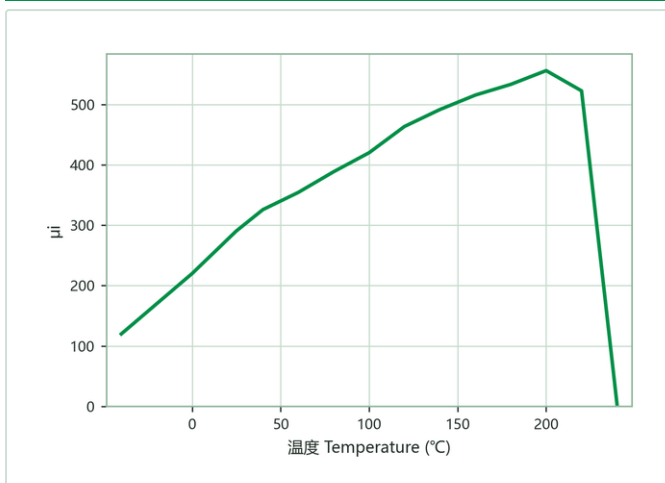
备注：各项数值均为环形磁芯T31×19×8测得的典型数值，由于几何形状和尺寸的影响，产品规格将与这些数据有所差异。25 °C 之功率损耗 P_{cv} 为 T31×19×8 环形磁芯绕线 3 匝实测。

Note: all values are typical data measured on a T31×19×8 toroidal core; actual product specifications will vary with geometry and size. P_{cv} values at 25 °C are measured on a T31×19×8 toroid wound with 3 turns.

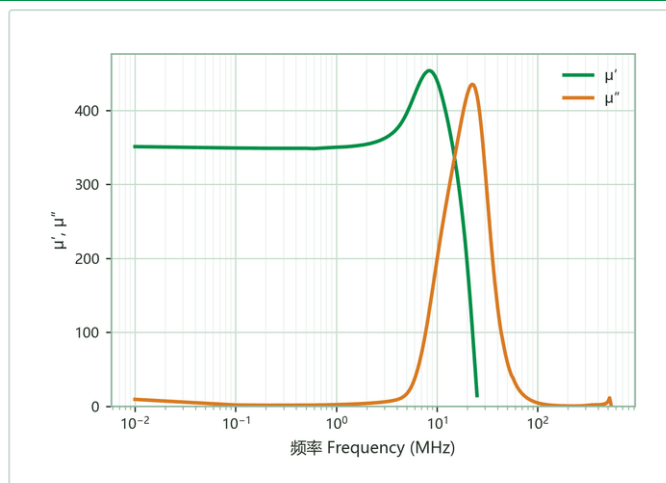
特性曲线详见次页 CHARACTERISTIC CURVES — SEE NEXT PAGE

DL3

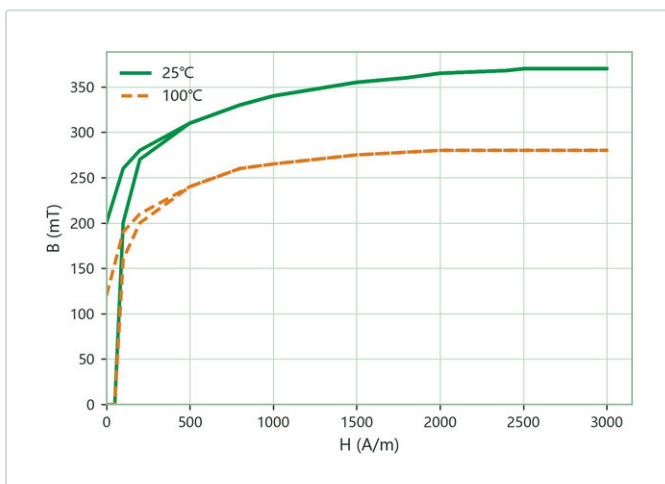
特性曲线 CHARACTERISTIC CURVES



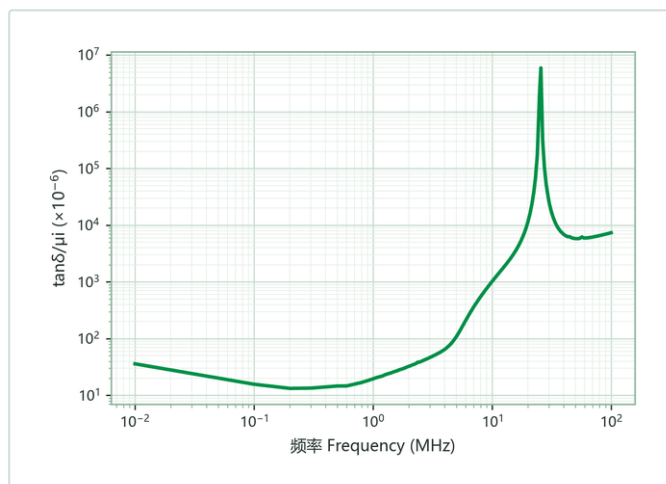
初始磁导率—温度特性
Initial Permeability vs. Temperature



复数磁导率—频率特性
Complex Permeability (μ' , μ'') vs. Frequency



静态磁化曲线
Static Magnetization Curves (B-H)



相对损耗因子—频率特性
Relative Loss Factor ($\tan\delta/\mu_i$) vs. Frequency